Making the ISOM Optical Memory Roadmap

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ABSTRACT

The International Symposium on Optical Memory (ISOM) committee made a technical roadmap of optical memory for the industry and academic. We focused on data storage capacities form 200 GB/disk to 1 TB/disk, and on data transfer-rate from 200 Mbps to 1 G bps. Thus, we will make milestones on our roadmap, so we and others can easily review our progress.

Key words: roadmap, optical memory.

1. BACKGROUND

For a long time, we have followed the trend of a combination of a short wavelength and a high NA. Fortunately, we have not required a roadmap because we just have to keep following the trend. Recently, however, the trend has begun breaking down. Then engineers feel uneasy about the future of our industry. Component and material manufacturers are troubled when planning future investment. Optical memory application designers have difficulty visualizing future applications. Therefore, the ISOM committee decided to make a technical roadmap for the industry and academic.

2. ORGANIZATION

The ISOM committee delegated two members as coordinators to promote the roadmap. The coordinators selected five future technology candidates that take major parts among the presentations in high density sessions. They nominated five members as organizers to play central roles in making roadmaps of each technology. The organizers brought together a group of about five engineers and researchers who are specialists in the some field of optical memory.

3. GUIDELINE and GOAL

We settled guidelines for making the roadmap as follows: We did not touch on the current business practices. Instead, we focused on data storage capacities form 200 GB/disk to 1 TB/disk, and on data transfer-rate from 200 Mbps to 1 G bps. Thus, we will make milestones on our roadmap, so we and others can easily review our progress.

4. PROCEDURE

We planed to start in April 2005 and finish at ISOM 2006 in October 2006. In midstream, Dr. Murakami, Chair of the ISOM steering committee, reported the intermediate results as the keynote speech at the ODS/ISOM 2005 meeting in July 2005[1].

The future technology is supported by many elemental technologies. To complete the roadmap, we had to investigate the interfaces between future and elemental technologies. Thus, we nominated five committee members to organize the following elemental technologies in December 2005: media, component, head, mastering & stamping, and signal processing.

We held two types of meeting to foster smoothly discussion between the future technology and elemental technology group, i.e. a meeting between organizers and one between group members of each technology group.

5. PRESENTATION

We presented the results of the future and elemental technology groups at ISOM2006 on 19th of October last year[2]. At this symposium, I will explain the outline of our activity and the summary of the ISOM road map.

6. AFTERWORD

We hope that our roadmap inspires not only engineers and researchers in our field but also people in related industry. In addition, we published the ISOM roadmap report and are calling for the application for the report on the ISOM web site (http://www.isom.jp/). The ISOM committee expresses gratitude to all group members and organizers who contributed to making the roadmap. We listed them at the last page of this report.

REFERENCES

- 1. Digest of ISOM lecture meeting 2005, Tokyo, December (2005)
- 2. Technical Digest of ISOM2006, We-NS-01, Takamatsu, October(2006)

Biographyies

Takeshi Maeda: He was born in Fukuoka, Japan, in 1948. He received the B.S., M.S. and Ph.D. degrees in electrical engineering from Waseda University, Japan, in 1971, 1973, 1998, respectively. Then, he has worked at Central Research Laboratory, Data Storage & Retrieval System Division, and Multimedia Systems R&D Division, Hitachi Ltd., Japan. Now, he is working at Storage Technology Research Center, Central Research Laboratory, Hitachi Ltd. He has developed many kinds of optical disks for thirty-three years, i.e. a video disk player, a digital audio disk, a digital optical disk, a digital versatile disk and Blu-ray disk. He mainly focused on developing servo system and read/write signal processing. Recently, he is interested in high density recording on optical disk. He is a member of the Institute of Electronics, Information and Communication Engineers of Japan and the Society of Applied Physics. Also he is a senior member of IEEE.

Role	First nam e	Last nam e	A ffiliation
Coordinator	Takeshi	M aeda	H itachi
	Jyun ji	Tom inaga	AIST

Technology	G roup	F i rst nam e	LastName	A ffiliation
		* Tetsuya	Iida	Pioneer
		Takuo	Tanaka	R IKEN
	M ulti-layer	Isao	Ich i m ura	Sony
	Mulli ayer	M otoyasu	Terao	H itachi
		Takashi	K ikukaw a	TDK
Future technobgy		Syuuichi	M aeda	MitsubishiChemical
	Two photon	* Yosh i masa	Kawata	Shizuoka Univ.
		Himoshi	Kubo	FujiFilm
		N or i h ito	N ish izaw a	Nagoya Univ.
		Tsuyoshi	Tsujioka	0 saka Kyoiku Univ.
		Kiyoshi	Yokom ori	R icho
	Hobgram	* Kazuhisa	Yam am oto	M atsushita
		* Tsutom u	Sh i m ura	University of Tokyo
		Toshio	Ando	JVC
		Tom oki	Kanesaka	Sony
		H irom i	Sakurai	AsahiG lass
		Kennichi	Kasazum i	M atsushita
		* Masataka	Shinoda	Sony
		Küchi	Uyeyanagi	JST
	Near field	Kenya	Goto	TokaiUniv.
		Tetsuya	Nishida	H itachi
 		M asakazu	H i rata	SII
		* Jyunji	Tom inaga	AIST
	Super—RENS	Takashi	N akano	AIST
		Takashi	K ikukaw a	TDK
		0 sam u	Nagum o	Pulstec
	M edia	* Reiji	Tam ura	HitachiMaxell
		Sum io	Ashida	Toshiba
		Shuichi	0 hkubo	NEC
		* Masahisa	Shinoda	M itsubishi
	Head	Kousei	Sano	M atsushita
		M asakazu	0 gasaw ara	Pionee r
Elem ental technology		Yoichi	Tsuchiya	Sanyo
		Himoshi	Fuji	Sharp
		* Shuichi	Ichiura	Sanyo
		Takeharu	A sano	Sony
		Toshio	Ando	JVС
	C om ponent	Shigeki	0 kauchi	Nichia
		M asaaki	0 nom ura	Toshiba
		Himoshi	Hatano	Konica M inolta
		Katsum i	Yoshizawa	Pioneer
	M astering & stam ping	* Minoru	Takeda	Sony
		Nobuyuki	Takam ori	Sharp
		Yasuo	Hosoda	Pioneer
		Seiji	M orita	Toshiba
		Takashi	0 hgo	JVC
		* Kunimaro	Tanaka	Teikyo Heisei Univ.
		Toshiaki	Iw anaga	NEC
	Signal processing	Yutaka	Kashihara	Toshiba
	o Ruarbiocessils	Hideki	Kobayashi	Pioneer
		M anabu	Yam am o to	Tokyo university of
		w anabu	ı allı allı 0 W	Science

* :0 rgan izer or co-organ izer